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PAPER

Preparation of AgInS₂ quantum dots/In₂S₃ cosensitized photoelectrodes by a facile aqueous-phase synthesis route and their photovoltaic performance

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Yuanqiang Wang^{*a*,*c*}, Qinghong Zhang^{*b*}, Yaogang Li^{**b*} and Hongzhi Wang^{**a*}

In aqueous-phase system, AgInS₂ quantum dots (QDs) sensitized TiO₂ photoanodes were *in situ* prepared by the reaction of β -In₂S₃ nanocrystals and as-prepared TiO₂/Ag₂S-QDs electrodes, followed by a covering process with ZnS passivation layer. A facile successive ionic layer adsorption and reaction (SILAR) method was adopted to obtain TiO₂/Ag₂S-QDs electrodes. β - In₂S₃ nanocrystals synthesized by chemical bath deposition (CBD) process serve as the reactant of AgInS₂ as well as buffer layer between the interfaces of TiO₂ and AgInS₂ QDs. Polysulfide electrolyte and Pt-coated FTO glass count electrode were used to test photovoltaic performance of the constructed devices. The characteristics of the sensitized photoelectric performance measurements. AgInS₂ is the main photo-sensitizer for TiO₂/AgInS₂-QDs/In₂S₃ electrodes and excess In₂S₃ appears on the surface of the electrodes. Based on optimal Ag₂S SILAR cycle, the best photovoltaic performance of prepared TiO₂/AgInS₂-QDs/In₂S₃ electrodes and excess In₂S₃ of 7.87 mA cm⁻² and power conversion efficiency (η) of 0.70% under full one-sun illumination was achieved.

Introduction

Semiconductor quantum dots sensitized solar cells (QDSSCs) have recently drawn significant attention since inorganic quantum dots (QDs) with narrow band gap and appropriate band positions are considered to be next generation alternative sensitizers of costly dyes in dye-sensitized solar cells (DSSCs).¹⁻⁸ In comparison with those binary ones,

^a State Key Laboratory for Modification of Chemical Fibers and Polymer Materials, College of Materials Science and Engineering, Donghua University, Shanghai 201620, People's Republic of China. E-mail: wanghz@dhu.edu.cn; Tel: +86-21-67792881; fax: +86-21-67792855

^b Engineering Research Center of Advanced Glasses Manufacturing Technology, Donghua University, Shanghai 201620, People's Republic of China. E-mail: yaogang_li@dhu.edu.cn

^c College of Chemistry and Chemical Engineering, Shanghai University of Engineering Science, Shanghai 201620, People's Republic of China.

† Electronic supplementary information (ESI) available: Photograph images, FESEM images, Optical absorption spectra, Photocurrent voltage characteristics of the photoelectrodes obtained by CBD of In_2S_3 and *in situ* reaction with different cycle of Ag₂S SILAR deposition on TiO₂ films. See DOI:

multicomponent chalcogenide semiconductor nanomaterials, such as CuInS₂, AgInS₂ and related materials have attracted much attention in recent years for application in solar light energy conversion systems.⁹⁻¹¹ AgInS₂ can crystallize in both the chalcopyrite and orthorhombic phases exhibiting direct band gap of 1.87 and 1.98 eV, respectively,¹² which is suitable for the absorption of visible light. And it can form good matching heterojunction with Ag₂S,^{13,14} Cu₂ZnSnS₄,¹⁵ CdS,¹⁶ or polymer matrix^{17,18} due to its suitable lattice constant, making it a promising alternative for solar cell materials. Importantly, AgInS₂ is low-toxic as opposed to the cadmium chalcogenides.

As one of the most important I-III-VI materials, AgInS₂ was extensively studied on the electrical and optical properties. So far, most of the studies focus on the synthesis strategies of AgInS₂ nanocrystals (NCs) for biological application.¹⁹⁻²³ And several methods have been adopted to fabricate AgInS₂ thin films such as chemical spray pyrolysis,^{24,25} physical vapor deposition,²⁶ and electrochemical deposition.²⁷ But these traditional preparation routes need harsh reaction conditions and the synthesized AgInS₂ films have poor crystal structure. Chemical bath deposition (CBD) and successive ionic layer adsorption and reaction (SILAR) routes were considered a convenient way to synthesize ternary sulphide thin films.^{28,29} Very recently, the $AgInS_2 NCs^{17}$ and Cu-doped $AgInS_2^{18} NCs$ have been incorporated in organic-inorganic hybride optoelectronic devices. Very poor total energy conversion efficiency is obtained for solar cells made using organic capped AgInS₂ NCs because the insulating organic ligands inhibit electron injection to core NCs.³⁰ It should be noted that ITO/ZnO/ZnS/AgInS₂/P3HT/Pt hybrid solar cells showed a

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power conversion efficiency (PCE) of 2.11%, which is the relatively highest value ever reported for ZnO-based all-solid-state hybrid solar cells. ³¹

Up to now, there are only few reports about AgInS₂ NCs sensitized solar cells. Nag et al. prepared AgInS₂ NCs by a post-synthesis annealing of NC dispersion that modifies the size and defect density of the NCs, and solution processed AgInS₂ NCs were used to form the photoanode of the QDSSCs exhibiting the PCE of 0.8% and short-circuit current density of 4.62 mA cm⁻².³² Torimoto et al. reported sandwich-type solar cells fabricated with the ZnS-AgInS2-loaded ZnO nanorod electrode as a working electrode and an acetonitrile solution containing the redox couple of I^{-}/I_{3}^{-} exhibited a photoresponse in the visble light region.³³ It has been reported in the literatures that the high conversion efficiency of ternary chalcogenides QDSSCs is generally caused by interfacial charge-transfer processes at TiO₂ film and QDs sensitizer.^{34,35} Approaches such as decreasing the charge recombination within the QDSSCs by modifying the blocking layer,³⁶ doping of CdS QDs with Mn^{2+} to improve the lifetime of trapped electron,³⁷ the deposition of Ru-dyes and QDs as hybrid photosensitizers, ³⁸ and a buffer layer³⁹ has been carried out. Applying a buffer layer such as In₂S₃ between TiO₂ and CuInS₂ can suppress the interface electron recombination so that improve the cell performance. 40,41 In₂S₃, a typical III-VI group sulphide, exists in three different structure forms: α -In₂S₃ (defect cubic structure), β - In_2S_3 (defect spinel structure) and γ -In₂S₃ (layered hexagonal structure). In fact, β -In₂S₃ is a well n-type photoactive semiconductor with a direct band gap about 2.0 eV, a relative large exciton Bohr radius approximately 34 nm and a high carrier mobility.^{42,43} To further improve the performance of chalcogenide-based solar cells, an intermediate band gap layer can be incorporated in a CIS solar cell to increase its photoelectric performance.³⁵ For this purpose, AgInS₂ QDSSCs embedded β -In₂S₃ layers should be developed.

Herein, for the first time, we fabricate $AgInS_2$ - QDs/In_2S_3 cosensitized solar cells by a facile aqueous-phase synthesis route. The growth process of $AgInS_2$ - QDs/In_2S_3 on TiO₂ film was demonstrated in detail. By using the Pt counter electrode (CE) and polysulfide electrolyte to assemble a QDSSC, the $AgInS_2$ - QDs/In_2S_3 co-sensitizers provide the PCE of 0.70% and the short-circuit current density of 7.87 mA cm⁻² under one-sun illumination.

Experimental section

Materials

Silver(I) acetate (Ag(OAc), 99+%), sodium sulfide (Na₂S·9H₂O, 98+%), indium chloride (InCl₃·4H₂O, 98+%), thioacetamide (CH₃CSNH₂, 98+%), citric acid (C₆H₈O₇·H₂O, 98+%), ethanol (99.5%), zinc acetate (Zn(OAc)₂·2H₂O, 99+%), sulfur (S, 99.5%), potassium chloride (KCl, 99.5%) were purchased from Sinopharm Chemical Reagent Co. (Shanghai, China). TiO₂ powder (P25, a mixed phase of 70% anatase and 30% rutile; average size 25nm+) from Degussa (Japan) was used to prepare TiO₂ anatase nanoparticles for photoelectrodes. Ethylcellulose and terpineol from Fluka (Germany) were used to suspend TiO₂ particles in viscous solutions. All the materials were used without further purification. Fluorine-doped tin oxide (FTO) conducting glass substrate (2.3 mm thick, 14 Ω/\Box) was purchased from Nippon Sheet Glass.

Preparation of TiO₂/Ag₂S-QDs electrodes

Mesoporous TiO₂ electrodes were prepared by following a method reported earlier.44,45 In brief, FTO glass was cleaned in a detergent solution using an ultrasonic bath for 15 min, and then rinsed with water and ethanol. Two layers of TiO₂ were deposited on FTO, a blocking layer and active layer. The blocking layer was deposited by treating the glass in a 40 mM TiCl₄ aqueous solution at 70 °C for 30 min followed by annealing at 500°C for 30 min. The active TiO₂ layer (P25 paste) was coated on top of the blocking layer by the doctor blade technique. The film was dried at 125 °C for 6 min followed by annealing 500 °C for another 30 min. A post treatment process of the calcined film was similar with that of blocking layer. The thickness of the TiO₂ mesoporous electrode was approximately 9 µm, measured by an optical profiler (Wyko NT9100, Veeco Co., USA). TiO₂/Ag₂S-ODs electrodes were subsequently prepared by SILAR method.⁴⁶ The electrode was dipped into 0.02 M Ag(OAc) aqueous solution for 30 s, rinsing with water, subsequent 30 s immersion in 0.05 M Na₂S aqueous solution followed by further rinsing with water. Each series of two immersions was considered as one SILAR cycle.

Fabrication of the AgInS₂-QDs/In₂S₃/ZnS QDSSCs

QDs-sensitized solar cells consisting of AgInS₂ QDs sensitizer with In₂S₃ buffer layer were prepared by CBD of In₂S₃ and in situ reaction with TiO₂/Ag₂S-QDs films with one-step method. A precursor aqueous solution of In₂S₃ was prepared from a mixture of InCl₃ (0.01 M), CH₃CSNH₂ (0.04 M). During the mixing procedure, C₆H₈O₇ (0.06 M) was added with the chemical solution for the formation of indium complexe. The resulting clear mixture was transferred into a 70 mL Teflonlined stainless steel autoclave, holding a vertically oriented FTO glass substrate (with a Ag₂S/TiO₂ film), which was then sealed and maintained at 150 °C for 3 h. The substrate was then rinsed with water and ethanol and dried at room temperature. The electrode was marked as TiO₂/AgInS₂(n)-QDs/In₂S₃ according to the different Ag₂S SILAR cycle (where n is Ag₂S SILAR cycle). All the electrodes analyzed in this study have been coated with ZnS, carried out by two SILAR cycle consisting of twice dipping alternatively in the 0.1 M Zn(OAc)₂ and 0.1 M Na₂S aqueous solution for 1 min per dip. The QDSSC was sealed in a sandwich structure with a spacer film (50 µm thick polyester film, DuPont) by using Pt-coated FTO glass. The space between the electrodes was filled with the polysulfide electrolyte which consisted of Na₂S (2 M), S (2 M), and KCl (0.2 M), using pure water as solvent. A mask with a window of 0.25 cm^2 was clipped on the photoanode side to define the active area of the cell.

Characterization

High-resolution transmission electron microscopy (HRTEM) images were obtained using a JEM 2100 F(JEOL Co., Japan) operating at 200 kV. The surface morphology and structure of the resulting films was studied using a field emission scanning electron microscope (FESEM, S-4800, Hitachi, Japan). The crystal structure was investigated by an X-ray diffraction technique (XRD, D/max 2550 V, Rigaku, Japan) with Cu Kα (λ = 0.154 nm) radiation at 40 kV and 200 mA in 20 ranging from 20° to 80°. X-ray photoelectron spectra (XPS) were recorded on an ESCALab MKII X-ray photoelectron spectrometer. UVabsorption spectra were recorded visible using а spectrophotometer (Lambda 950, Perkin-Elmer Co., USA). Photocurrent-voltage characteristics (J-V curves) of QDSSCs were measured using a Keithley 2400 Source Meter under

illumination of simulated sunlight (100 mW cm⁻²) provided by a Newport solar simulator (Model 96160) with an AM 1.5G filter. Incident photon-to-current conversion efficiency (IPCE) spectra were measured as a function of wavelength from 350 to 800 nm using a specially designed IPCE system (Newport, USA) for the QDSSCs.

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Results and discussion

In aqueous-phase system, AgInS2-QDs sensitized TiO2 photoanodes were *in situ* prepared by the reaction of β -In₂S₃ nanocrystals and as-prepared TiO2/Ag2S-QDs electrodes. TiO₂/Ag₂S-QDs electrodes were obtained by a facile successive ionic layer adsorption and reaction (SILAR) method. β -In₂S₃ nanocrystals synthesized by chemical bath deposition (CBD) process serve as the reactant of AgInS₂ as well as buffer layer between the interfaces of TiO₂ and AgInS₂ QDs. The overall reactions are presented as the follow:

$$Ag^{+} + S^{2-} \rightarrow Ag_{2}S$$
(1)
(The reaction was processed on TiO₂ films)

$$L \rightleftharpoons L^{-} + H^{+}(L \text{ is citric acid})$$
(2)

$$In^{3+} + L^{-} \rightleftharpoons InL_{3}$$
(3)

$$CH_{3}CSNH_{2} + H^{+} \rightarrow CH_{3}CNH^{+} + H_{2}S$$
(4)

$$U \bowtie L^{-} + U^{+} \Rightarrow S^{2-} + 2U^{+}$$
(5)

 $H_2S \rightleftharpoons HS$ (5)+H+ 2H

 $In^{3+} + S^{2-} \rightarrow In_2S_3$ (6)(7)

 $Ag_2S + In_2S_3 \rightarrow 2AgInS_2$

The high-resolution TEM (HRTEM) image of the TiO₂/AgInS₂-QDs/In₂S₃ composite in Fig. 1 clearly depicts the crystalline lattice fringes of the involved species. The lattice spacing distance of 0.352 nm, illustrated in the right zone of the image, corresponds to the (101) plane of anatase TiO_2 . The lattices with spacing distances of 0.334 and 0.325 nm round TiO_2 particle encompassed by red lines correspond to the (112) plane of the tetragonal AgInS₂ (JCPDS file no. 75-0117) and (311) plane of the In_2S_3 (JCPDS file no. 84-1385), respectively. The In₂S₃ coating with CBD method is in close contact with both the AgInS₂ QDs and TiO₂ particles.



Fig. 1 HRTEM image of TiO₂/AgInS₂(6)-QDs/In₂S₃ electrode.

Fig. 2 shows a series of color changes for the TiO₂ electrodes after sensitization in the reaction process. TiO₂/In₂S₃ electrode was prepared as a reference. The TiO₂ film was originally white and semi-transparent, becoming black-brown when it was coated with Ag₂S QDs and red-brown when it coated with AgInS₂-QDs/In₂S₃. Due to the quantum confinement effect in the optics, the color for the $TiO_2/AgInS_2$ -QDs/In₂S₃ electrode is distinct with black bulk AgInS2. It was also found that the color of TiO₂/AgInS₂-QDs/In₂S₃ electrode changes from pale redbrown to dark reddish brown, indicating the increase of AgInS₂-QDs layer thickness (see Fig. 1S[†]). The present claybank color on TiO₂/AgInS₂-QDs/In₂S₃ electrodes indicates the deposition of In_2S_3 films on the bare FTO glass.







Fig. 3 (a) FESEM images (top view) of (a) plain TiO₂ film, (b) TiO₂/Ag₂S-QDs electrode prepared by 6 cycles of Ag₂S SILAR deposition, (c) TiO_2/In_2S_3 electrode prepared by In_2S_3 CBD deposition and (d) TiO₂/AgInS₂(6)-QDs/In₂S₃ electrode.

FESEM images in Fig. 3 demonstrate the surface topography of the electrodes at different reaction stages. SILAR method was used to deposit Ag₂S on TiO₂ films as the basic electrode, and the growth mechanism of the Ag₂S-QDs on the TiO₂ films was monitored with FESEM image (see Fig. 3a, b). It is clear that the entire surface of the FTO substrate is covered uniformly and densely with TiO₂ nanoparticles from Fig. 3a. The average particle diameter is approximate 30 nm and the average pore size among TiO₂ nanoparticles is less than 10 nm. After assembled with Ag_2S for 6 cycles, the TiO₂ nanoparticles structure is retained, and the Ag₂S particles could be generated in the pores as well as on the surface of porous TiO_2 films as shown in Fig. 3b. In addition, the small diameter of pores of the TiO₂ films restricts further growth of the Ag₂S particles. Thus, Ag₂S particles were smaller in the porous TiO₂ films, meaning that the size of Ag_2S is in the scope of quantum dot. Fig. 3c shows the surface topography of TiO2/In2S3 film prepared by CBD method as comparison. The surface of the as-deposited film shows a uniform granular structure with very-well-defined grain boundaries and with some larger grains dispersed on the film surface. The grains have an irregular round shape. Fig. 3d shows the surface morphology of $AgInS_2(6)$ -QDs/In₂S₃ cosensitized TiO₂ electrode. It was found that AgInS₂ nanoparticles with pyramid-like shape appear on the surface of the film. The surface morphology of TiO₂/AgInS₂-QDs/In₂S₃ films prepared with different Ag₂S SILAR cycle seem to be slightly affected by the Ag₂S SILAR cycles (see Fig. 2S⁺). All the samples show the similar surface morphology, however, as the Ag_2S SILAR cycle increases, the pyramid-like structure becomes denser and the size of $AgInS_2$ particles become larger on the surface of electrode.

The valence states and composition of the surface of $TiO_2/AgInS_2(6)-QDs/In_2S_3$ electrode were further investigated by XPS (see Fig. 4).



Fig. 4 XPS survey, Ag 3d, In 3d, S 2p, Ti 2p and O 1s of the surface of $TiO_2/AgInS_2(6)$ -QDs/In₂S₃ electrode.

Table 1 The elementary composition of calculated from XPS spectrum of the surface of $TiO_2/AgInS_2(6)$ -QDs/In₂S₃ electrode.

Name	Peak Binging Energy (eV)	FWHM (eV)	Atomic (%)	
Ag3d	367.4	0.94	2.3	
In3d	444.4	1.1	22.41	
S2p	161.2	1.12	27.81	
Ti2p	458.5	1.09	29.48	
Ols	529.9	1.31	17.99	

The Ag 3d, In 3d, S2p, Ti2p and O1s were examined, respectively, which confirm the presence of these elements in the typical sample. The binding energies of Ag $3d_{3/2}$ and Ag $3d_{5/2}$ for AgInS₂ were located at 373.5 eV and 367.4 eV with a peak splitting of 6 eV, which is consistent with the standard reference XPS of Ag⁺. The In 3d peaks were located at 444.4 eV and 451.9 eV with a peak splitting of 7.5 eV, matching well with In³⁺. The S 2p peaks splitting of 161.2 eV and 162.3 eV with a peak splitting of 1.1 eV, which corresponds to a binding energy of S^{2-.47} The Ti 2p spectra exhibits two peaks corresponding to the binding energies of 458.5 eV (Ti $2p_{3/2}$)

and 464.2 eV (Ti $2p_{1/2}$), resulting from the Ti of TiO₂. The binding energies of O 1s were located into two peaks, the peak at 529.9 eV, resulting from the crystal lattice oxygen of TiO₂ and the peak at 532 eV, corresponding to the hydroxyl oxygen. It can be seen in Table 1 through the quantification of peaks, there are excess In, S elements according to the stoichiometric coefficient of AgInS₂, showing the sensitizers consist of AgInS₂ and In₂S₃ over the electrode. And there are excess O elements according to the stoichiometric to the hydroxyl oxygen on the surface of the sample.

To explore the formation process of $AgInS_2$ -QDs/In₂S₃ cosensitized electrodes, the TiO₂ electrodes after sensitization at different reaction stages were monitored by XRD analyses in Fig. 5. There are unconspicuous Ag_2S diffraction peaks according to the similar XRD patterns of TiO₂/Ag₂S(6) electrode and TiO₂ electrode, showing the size of Ag₂S is in quantum dot range. In addition, it is also not easy to determine AgInS₂ phase (JCPDS file no. 75-0117) over AgInS₂(6)-QDs/In₂S₃ co-sensitized TiO₂ electrode due to smaller size of AgInS₂ QDs and the higher intensity of the TiO₂ (P25) diffraction peak. However, the main diffraction peaks such as (111), (400) and (511) diffraction peaks of β -In₂S₃ (JCPDS file no. 84-1385) appear on the XRD pattern of AgInS₂-QDs(6)/In₂S₃ co-sensitized electrode, indicating that there are excess β -In₂S₃ over the electrode.



Fig. 5 XRD patterns of plain TiO₂ film, TiO₂/Ag₂S(6)-QDs electrode prepared by 6 cycles of Ag₂S SILAR deposition, TiO₂/In₂S₃ electrode prepared by In₂S₃ CBD deposition and TiO₂/AgInS₂(6)-QDs/In₂S₃ electrode.

UV-vis absorption spectroscopy was used to track the formation of AgInS2-QDs/In2S3 co-sensitized electrodes and investigate the suitability for photovoltaic application. Fig. 6 shows the absorption spectra of the correlative electrodes during the preparation process of TiO₂/AgInS₂-QDs/In₂S₃ photoanode that from the plain TiO2, TiO2/Ag2S-QDs to TiO₂/AgInS₂-QDs/In₂S₃ electrode. TiO₂/In₂S₃ electrode was chosen as a comparison. The spectrum shows that the plain TiO₂ can mainly absorb UV light with wavelength smaller than 420 nm. The TiO₂/Ag₂S-QDs electrode can absorb UV to nearinfrared light, but its optical absorption ability is rather weak, probably being bad for solar cell performance. The TiO₂ film with In₂S₃ CBD deposition, the light absorbance of the electrode was enhanced in the visible region, and its absorption band edge is about 530 nm. The prepared TiO₂/AgInS₂- QDs/In_2S_3 electrode has excellent optical absorption performance not only UV region, but also in the visible region. A shoulder appears between 530 and 600 nm with a long tail

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extending to longer wavelengths, which is mainly due to the formation of the AgInS₂ layer coated on the TiO₂ electrode. These results confirm that AgInS₂ layer can effectively improve the light absorption property of TiO₂ film. It was also found that the absorption spectra of the TiO₂/AgInS₂-QDs/In₂S₃ electrodes obtained by CBD of In₂S₃ and *in situ* reaction with different cycles of Ag₂S SILAR deposition on TiO₂ film are similar (see Fig. 3S†). The absorption spectra of the prepared TiO₂/AgInS₂-QDs/In₂S₃ electrodes were red-shifted with the increase of the Ag₂S SILAR cycles probably because of the increase of AgInS₂-QDs size or the increase of AgInS₂-QDs layer thickness. The enhanced absorption in the longer wavelength region is probably due to the remission of quantum confinement effect on the AgInS₂ QDs.

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Fig. 6 Optical absorption spectra of the plain TiO₂ film, TiO₂/Ag₂S-QDs electrode prepared by 6 cycles of Ag₂S SILAR deposition, TiO₂/AgInS₂(6)-QDs/In₂S₃ electrode and TiO₂/In₂S₃ electrode prepared by CBD of In₂S₃ for 3 h on the plain TiO₂ film.

We fabricated QDSSCs using the FTO/TiO₂/AgInS₂-QDs/In₂S₃/ZnS as the photoanode and a Pt electrode as the cathode along with a polysulfide electrolyte between the electrodes. Fig. 7 shows schematic descriptions of the working principle of a QDSSC and its charge transfer mechanism, respectively. β-In₂S₃ QDs obtained by CBD method react with as-prepared Ag₂S QDs in the holes of TiO₂ films to form AgInS₂@In₂S₃ QDs and there are also excess AgInS₂ and In₂S₃ particles on the surface of the electrodes. AgInS₂ QDs absorb photons and generate electron-hole pairs. These photogenerated electrons can be efficiently transferred from AgInS₂ QDs to the mesoporous TiO_2 layer, finally collected by the FTO glass contact. Moreover, there are non-radial recombination electron and hole via the defect state as marked in Fig. 7(b) with a green dotted arrow.³² At the same time, the photo-generated holes are scavenged by the polysulfide based redox electrolyte. AgInS2-QDS/In2S3 surface was passivated with a wider band gap semiconductor (ZnS, 3.6 eV)⁴⁸ to prevent the leakage of current from AgInS₂-QDS/In₂S₃ to the electrolyte.



Fig. 7 Schematic diagrams representing the working principle and charge transfer mechanism of TiO₂/AgInS₂-QDs/In₂S₃ QDSSC.

Fig. 8 presents the photocurrent-voltage characteristics (J-V) $TiO_2/AgInS_2-QDs(6)/In_2S_3$ co-sensitized curves) of the photonaode with Pt counter electrode and polysulfide electrolyte. TiO₂/In₂S₃ electrode prepared by CBD of In₂S₃ on TiO_2 film for 3 h and $TiO_2/Ag_2S(6)$ -QDs electrode prepared by SILAR method were used as comparison. The intermediate values for the main resultant photovoltaic parameters based on five parallel cell devices and the error intervals of PCE (η) are summarized in Table 2. For the cell based on just Ag₂S(6)-QDs or In₂S₃ sensitized TiO₂ photo-electrode, a short-circuit photocurrent density (J_{sc}) of 0.49 or 1.19, an open-circuit photovoltage (V_{oc}) of 0.19 or 0.23 V, a fill factor (FF) of 0.34 or 0.31 and a PCE (η) of 0.03 or 0.08 were revealed respectively. The poor photovoltaic performance may be attributed to the poor light absorption ability or the unmatched energy level. For AgInS₂(6)-QDs/In₂S₃ co-sensitized QDSSC, the J-V curve reveals that $J_{sc}=7.87$ mA cm⁻², $V_{oc}=0.32$ V, and η =0.70%, which are higher than those of TiO₂/Ag₂S(6)-QDs and TiO₂/In₂S₃ electrodes. The higher photocurrent density and efficiency is probably because of the broader light absorption spectrum and the better charge carriers generation ability of AgInS₂ QDs for AgInS₂(6)-QDs/In₂S₃ co-sensitized TiO₂ photo-electrode. In general, the current density for QDSSCs are determined by the initial number of photo-generated charge carriers, the electron injection efficiency from QD-sensitizers to photo-electrodes, and the recombination rate between the injected electrons and holes of excited QDs or redox species in the electrolyte. The IPCE is defined as the number of photogenerated charge carriers contributing to the current per incident photon. Fig. 9 compares the IPCE spectra of the QDSSCs. The IPCE spectra of the QDSSCs were basically consistent with the corresponding UV-Vis spectra shown in Fig.6. TiO₂/AgInS₂-QDs(6)/In₂S₃ QDSSC shows a maximum IPCE of about 37% from 500 to 625 nm, which is much higher than that of TiO_2/In_2S_3 and $TiO_2/Ag_2S(6)$ -QDs electrodes.

Therefore, we believe that AgInS₂-QDs are the main photosensitizers. On the other hand, the lower FF indicates the increasing of carrier recombination on the interfaces between TiO₂ and QDs sensitizer or electrolyte and CE. It is well known that Pt is not a good catalyst for polysulfide regeneration, which leads to poor fill factors for QDSSCs because their surface activity and conductivity are suppressed as result of adsorption of the sulfur atom.⁴⁹ The lower open-circuit photovoltage of TiO₂/AgInS₂-QDs(6)/In₂S₃ QDSSC may be due to the surface defects of the synthesized AgInS₂ QDs. β -In₂S₃ serves not only as the reactant of AgInS₂ but also intermediate band gap layer that may change the unmatched band alignments in the heterostructure between TiO₂ and AgInS₂ QDs. However, the excess β -In₂S₃ particles on the surface of TiO₂/AgInS₂-QDs/In₂S₃ co-sensitized photonaodes lead to unhomogeneous In₂S₃ deposition, which may affect the surface state of the AgInS₂ QDs.

In addition, based on the same construction for the given $TiO_2/AgInS_2-QDs/In_2S_3$ QDSSCs system, it is reasonable that the photocurrent density and energy conversion efficiency are directly affected by the initial Ag₂S SILAR cycles (See Fig. $4S^{\dagger}$ and Table 1 S^{\dagger}). With increasing the Ag₂S SILAR deposition from 2 cycles to 6 cycles, the J_{sc} of TiO₂/AgInS₂- QDs/In_2S_3 photoanodes increases substantially from 3.39 to 7.87 mA cm⁻². The increase of J_{sc} is attributed to extending the light absorption range and the increase in absorption ability with red-shift of the absorption onset of AgInS₂-QDs/In₂S₃ sensitizer. The increase of incorporated amount of AgInS₂-ODs can not only contribute to absorb more photons to generate more photoexcited electrons, but also form a uniform and dense shell to reduce direct contact areas between the bare TiO₂ surface and polysulfide electrolyte.^{50, 51} However, the J_{sc} and η were found to decrease when the Ag₂S coating increased to 8 cycles. The possible reason for the reduced cell performance may be attributed to the aggregations and growth of the Ag₂S QDs (See Fig. 2S[†]), which will result in the presence of subsequently synthesized AgInS2 QDs with no direct contact with the TiO₂, leading to block the infiltration of the electrolyte into the photoelectrode, thereby decreasing the regeneration efficiency of the solar cell.52,53



Fig. 8 Photocurrent voltage characteristics of QDSSCs based on TiO_2/Ag_2S (SILAR for 6 cycles), TiO_2/In_2S_3 (CBD for 3h), $TiO_2/AgInS_2(6)$ -QDs/In₂S₃ electrodes.

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electrodes.								
Photoanode	J_{sc} (mA cm ⁻²)	V _{oc} (V)	FF	η (%)				
$TiO_2/Ag_2S-QDs(6)$	0.49	0.19	0.34	0.03±0.01				
TiO_2/In_2S_3	1.19	0.23	0.31	0.08±0.01				
$TiO_2/AgInS_2(6)\text{-}QDs/In_2S_3$	7.87	0.32	0.28	0.70 ± 0.02				



Fig. 9 IPCE spectra of QDSSCs based on TiO₂/Ag₂S (SILAR for 6 cycles), TiO₂/In₂S₃ (CBD for 3h), TiO₂/AgInS₂(6)-QDs/In₂S₃ electrodes.

Conclusions

As one of the most important I-III-VI materials, AgInS₂ was extensively studied on the electrical and optical properties, and the reports about AgInS₂ QDs sensitized solar cells are quite few. In this study, for the first time, we have presented a facile aqueous-phase synthesis route to prepared QDssensitized photoelectrodes consisting of AgInS2-QD/In2S3 cosensitizers based on CBD of In₂S₃ and in situ reaction with TiO₂/Ag₂S-QDs films obtained by SILAR method. AgInS₂-QDs are the main photo-sensitizers. AgInS₂ nanoparticles with pyramid-like shape and excess In_2S_3 layer were found on the surface of the $TiO_2/AgInS_2-QDs/In_2S_3$ electrodes. The TiO₂/AgInS₂(6)-QDs/In₂S₃ QDSSC shows the better photovoltaic performance with J_{sc} of 7.87 mA cm⁻², η of 0.70% and maximum IPCE of about 37% than those of the $TiO_2/Ag_2S(6)$ -QDs and TiO_2/In_2S_3 QDSSCs attributing to the broader light absorption spectrum and the better charge carriers generation ability of AgInS₂ QDs for AgInS₂(6)-QDs/In₂S₃ cosensitized TiO₂ photo-electrode. The absorption spectra of the prepared $TiO_2/AgInS_2-QDs/In_2S_3$ electrodes were red-shifted with the increase of the Ag₂S SILAR cycles probably because of the increase of AgInS₂-QDs size or the increase of AgInS₂-QDs layer thickness. Based on the same construction for the given TiO₂/AgInS₂-QDs/In₂S₃QDSSCs system. the photocurrent density and energy conversion efficiency are directly affected by the initial Ag₂S SILAR cycles. We expect that this facile synthesis method should provide an insight into the fabrication of heterojunction thin film solar cells based on multicomponent chalcogenide.

Journal Name

Acknowledgements

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